

Valved RF Cracker

For atomic As, P, S, Se, Sb, Te

The QC500

The patented QC500 valved cracker enables the generation of *atomic* species from solid group V and VI elements. The cracker incorporates a generous 500cc sublimator zone as well as a red-to-white conversion zone (for phosphorous) to avoid pressure bursts seen in conventional two-zone crackers. The sublimated material passes through a high-purity all-quartz valve into an RF cracking zone. In contrast to a thermal cracking zone, the RF plasma acts to dissociate the material to the more reactive atomic form allowing higher growth rate and dopant incorporation to be achieved.

The RF cracking zone can also be used to generate atomic nitrogen or oxygen for high-quality oxide or nitride growth.

The high-purity quartz valve is actuated externally by a conventional manual or motorised linear drive and is located close to the RF cracking zone for rapid dose control.

The sublimator zone and discharge cracking zone are surrounded by water-cooled shielding, thus reducing the thermal load on the system. The sublimator housing can be indepenently removed on guide rails for easy replenishment of source material.

Applications

- Group V and VI cracking
- Doping, bulk growth
- Improved sticking efficiencies

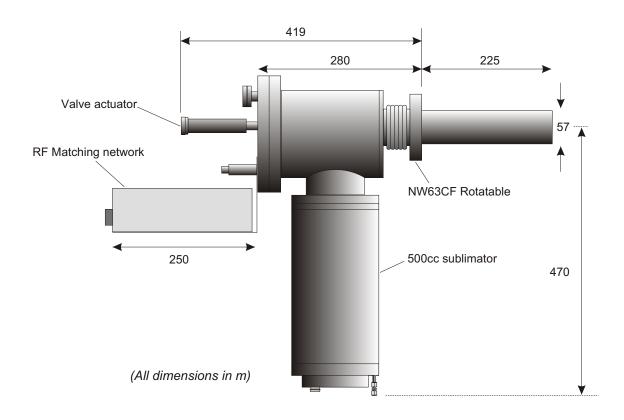
Features

- Atomic species
- Low thermal load
- Valved flux regulation
- Universal cracker
- High sublimator capacity



QC500

Specification



Specification - QC500

Mounting	NW63CF
Sublimator capacity	500cc
Max. RF power	500W
Beam Diameter	Divergent. 25mm at source exit
Sublimator/buffer temperature	Max. 450 °C
Valve material	High-purity quartz
In-vacuum Length	225mm
In-vacuum diameter	57mm

Options

Automatic tuning unit. Motorised valve actuator. Plasma monitor

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